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TITLE: WAVEGUIDE STRUCTURE AND METHOD OF ORMING THE

WAVEGUIDE STRUCTURE

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ABSTRACT

A method for forming a high optical confinement waveguide structure by: forming a sincon-based waveguide on a substrate by depositing a vaveguide layer of silicon containing material onto the substrate. The material is selected in a manner such that the refractive index of the waveguide is great than the refractive index of the substrate. The silicon-based waveguide is a rther formed by etching the deposited waveguide structure such as to form a respective in the deposited waveguide layer. An optical signal processing element is formed in and integrated with the deposited waveguide layer.